JUN 1 3 2002 BY

Docket No.: 49657-801

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Tomohide TERASHIMA

Serial No.: 09/661,035

Filed: September 13, 2000

For: SEMICONDUCTOR DEVICE

Group Art Unit: 2811

Examiner: LOKE, Steven Ho Yin

AMENDMENT

Commissioner for Patents Washington, DC 20231

Sir:

The Following Amendments and Remarks are submitted in response to the Office Action dated March 13, 2002.

IN THE SPECIFICATION:

Please delete the title and insert the following new title:

- SEMICONDUCTOR DEVICE WITH REGION THAT CHANGES DEPTH

ACROSS THE DIRECTION OF CURRENT FLOW --.

Please replace the paragraph beginning at page 10, line 19, with the following rewritten paragraph:

Assuming that N-type epitaxial layer 2 has an impurity concentration of N_A, P-type diffusion region 7 has an impurity concentration of N_D, neighboring P-type diffusion regions 7 are spaced by a distance of W, a required breakdown voltage is V, an amount of

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